5. The method of claim 4, wherein the first and second topographies each have an orientation axis and wherein the orientation axes are nonaligned with respect to each other while exposing the resin layer to the patterned irradiation.

6. The method of claim 1, wherein the first microstructured surfaces has a first topography and the second microstructured surfaces has a second topography, and wherein the first and second topographies are identical with respect to each other.

7. The method of claim 6, wherein the first and second topographies each have an orientation axis and wherein the orientation axes are nonaligned with respect to each other while exposing the resin layer to the patterned irradiation.

8. The method of any preceding claim, wherein the second microstructured surface comprises a release agent.

9. The method of any preceding claim, further comprising applying a release coating to the modified microstructured surface on the modified molding tool.

10. The method of any preceding claim, further comprising replicating a microstructured article having a microstructured surface complementary to the pattern of the matrix of first microstructural features and the at least one discontinuous region of second microstructural features.

11. The method of any one of claims 1 to 9, further comprising replicating a metallic tool from the modified molding tool.

~~12. An article having a first major surface comprising first microstructural features within a matrix of second microstructural features, wherein the first microstructural features are discontinuous, wherein collectively the first and second microstructural features form a pattern visible at least when viewed normal to the first major surface, and wherein the first and second microstructural features are independently selected from the group consisting of cones, diffraction gratings, lenticulars, segments of a sphere, pyramids, cylinders, fresnels, and prisms, wherein the first and second microstructural features independently comprise at least one of a thermosetting material or a thermoplastic material.~~

~~13. The article of claim 12, wherein the first and second microstructural features independently have a pitch in a range from 0.1 micrometer to 1000 micrometers.~~

~~14. The article of claim 13, wherein the first pitch is up to 90% of the second pitch.~~

~~15. The article of claim 13, wherein the first pitch is up to 50% of the second pitch.~~

~~16. The article of any one of claims 12 to 15, wherein the pattern includes at least one of alphanumerics, a first trademark indicia, or a first copyrighted indicia.~~

~~17. The article of any one of claims 12 to 16, wherein the pattern comprises regions having no microstructural features.~~

~~18. An article having a first major surface comprising first microstructural features and second microstructural features arranged in a pattern visible at least when viewed normal to the first major surface, wherein the first and second microstructural features are different relative to each other, and are selected from the group consisting of cones, diffraction gratings, lenticulars, segments of a sphere, pyramids, cylinders, fresnels, and prisms, wherein the first and second microstructural features independently comprise at least one of a thermosetting material or a thermoplastic material.~~

~~19. The article of claim 18, wherein the first and second microstructural features independently have a pitch in a range from 0.1 micrometer to 1000 micrometers.~~

~~20. The article of claim 19, wherein the first pitch is up to 90% of the second pitch.~~

~~21. The article of claim 19, wherein the first pitch is up to 50% of the second pitch.~~

~~22. The article of any one of claims 18 to 21, wherein the pattern includes at least one of alphanumerics, a first trademark indicia, or a first copyrighted indicia.~~

~~23. The article of any one of claims 18 to 22, wherein the pattern comprises regions having no microstructural features.~~